

PATENT NUMBER

SCANNED LR ⁽²⁾ O.I.P.E. let O.A.

PATENT DATE

APPLICATION NO. 09/648111	CONT/PRIOR F	CLASS 257 438	SUBCLASS 5911	ART UNIT 2815	EXAMINER BROCK
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APPLICANTS: Kwang-Jo Hwang

TITLE: Method of patterning a metal layer in a semiconductor device

PTO-2040
12/89

[illegible]

<input type="checkbox"/> TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.	_____ (Assistant Examiner) (Date)			NOTICE OF ALLOWANCE MAILED	
<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S Patent. No. _____ _____ _____	_____ (Primary Examiner) (Date)			ISSUE FEE	
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